

Single Event Radiation Hardened Quad Voltage Comparator



The single event effects and total dose radiation hardened IS-139ASRH consists of four independent single or dual supply

voltage comparators on a single monolithic substrate. The common mode input voltage range includes ground, even when operated from a single supply, and the low supply current makes these comparators suitable for low power applications. These types were designed to directly interface with TTL and CMOS inputs.

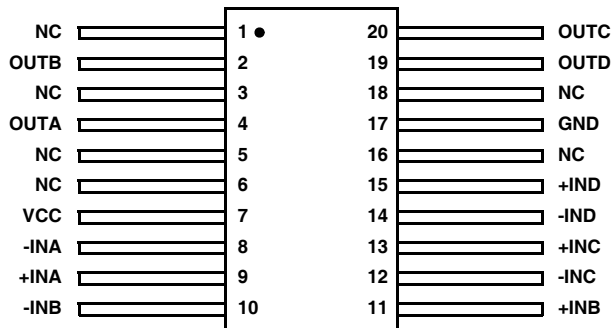
The IS-139ASRH is fabricated on our dielectrically isolated Rad Hard Silicon Gate (RSG) process, which provides immunity to single event latch-up and the capability of highly reliable performance in any radiation environment.

Specifications for Rad Hard QML devices are controlled by the Defense Supply Center in Columbus (DSCC). The SMD numbers listed below must be used when ordering.

Detailed Electrical Specifications for the IS-139ASRH are contained in SMD 5962-01510. A “hot-link” is provided on the Intersil website for downloading.

Pinout

**IS9-139ASRH
(FLATPACK CDFP4-F20)
TOP VIEW**



Features

- Electrically Screened to SMD # 5962-01510
- QML Qualified per MIL-PRF-38535 Requirements
- Radiation Hardness
 - Total Dose. 300krad(Si) (Max)
 - Single Event Latch-up >84MeV/mg/cm²
 - Single Event Upset >84MeV/mg/cm²
- Operating Supply Voltage Range. 9V to 30V
- Input Offset Voltage (V_{IO}). 5mV (Max)
- Quiescent Supply Current 3mA (Max)
- Differential Input Voltage Range Equal to the Supply Voltage

Applications

- DC-DC Power Conversion
- Pulse Generators
- Timing Circuitry
- Level Shifting
- Analog to Digital Conversion

Ordering Information

ORDERING NUMBER	INTERNAL MKT. NUMBER	TEMP. RANGE (°C)	PACKAGE DRAWING NUMBER
5962F0151001VXC	IS9-139ASRH-Q	-55 to +125	K20.A
5962F0151001QXC	IS9-139ASRH-8	-55 to +125	K20.A
IS9-139ASRH/PROTO	IS9-139ASRH/PROTO	-55 to +125	K20.A

Die Characteristics

DIE DIMENSIONS

3750 μ m x 4510 μ m (148 mils x 178 mils)
483 μ m \pm 25.4 μ m (19 mils \pm 1 mil)

INTERFACE MATERIALS

Glassivation

Type: Silox (SiO₂)
Thickness: 8.0k Å \pm 1.0k Å

Top Metallization

Type: AlSiCu
Thickness: 16.0k Å \pm 2k Å

Substrate

Radiation Hardened Silicon Gate, Dielectric Isolation

Backside Finish

Silicon

ASSEMBLY RELATED INFORMATION

Substrate Potential

Unbiased (DI)

ADDITIONAL INFORMATION

Worst Case Current Density

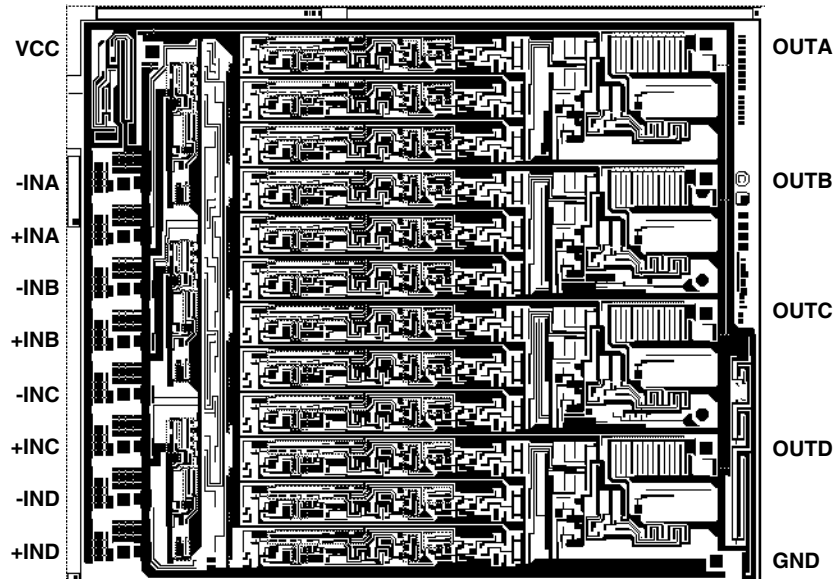
$<2.0 \times 10^5$ A/cm²

Transistor Count

644

Metallization Mask Layout

IS-139ASRH



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